

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: Crocker et al.

Title: Nanometer-Scale Engineered Structures,  
Methods and Apparatus for Fabrication thereof,  
and Applications to Mask Repair,  
Enhancement, and Fabrication

Appl. No.: 10/689,547

Filing Date: 10/21/2003

Examiner: Ruggles

Art Unit: 1756

**TRANSMITTAL OF CORRECTED FORMAL REPLACEMENT FIGURES**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Transmitted herewith are the corrected formal replacement figures (1-2 sheets, Figures 19 and 21) in response to the Examiner's objection in the above-identified application.

Applicants submit that the attached replacement figures overcome the objections raised by the Examiner in the January 19, 2007 office action.

Respectfully submitted,

Date June 4, 2007

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